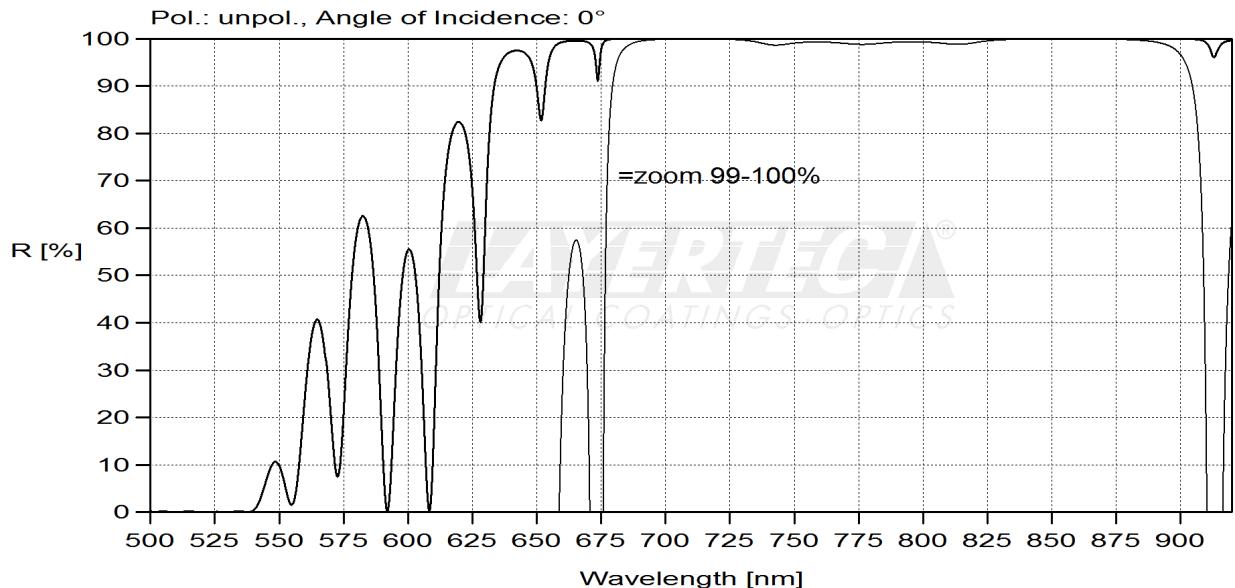


Magnetron sputtered system

HR( $0^\circ$ ,(690-890) $\pm$ 5nm) $>99.9\%$  + R( $0^\circ$ ,532nm) $<2\%$   
GDD( $0^\circ$ ,(700-880) $\pm$ 10nm) $\sim$ 0fs $^2$ fig. 1 reflection,  $0^\circ$ fig. 2 calculated GDD-Rp,  $0^\circ$ 